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| Substitute Form PTO-1449 (Modified) | U.S. Department of Commerce Patent and Trademark Office | Attorney's Docket No. 14564-006002 | Application No. 10/778,019 |
| Information Disclosure Statement by Applicant (Use several sheets if necessary) (37 CFR §1.98(b)) | | Applicant Garbuzov et al. | |
| | | Filing Date February 13, 2004 | Group Art Unit 2828 |

| U.S. Patent Documents | | | | | | | |
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| Examiner Initial | Desig. ID | Document Number | Publication Date | Patentee | Class | Subclass | Filing Date If Appropriate |
| | AA | | | | | | |
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| Foreign Patent Documents or Published Foreign Patent Applications | | | | | | | | |
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| Other Documents (include Author, Title, Date, and Place of Publication) | | |
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| Examiner Initial | Desig. ID | Document |
| | AQ | Ito, R. and Nakamura, M., Foundation and Application of Semiconductor Laser, BAIFUKAN CO., LTD., 1st Edition, 5th printing, pp. 50-53 and 82-84, March 30, 1995 (Japan), English translation (Japanese language version was previously submitted). |
| | AR | |
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